R elevance of the EEL spectroscopy for in-situ studies of the growth mechanism of copper-phthalocyanine molecules on metal surfaces: A 1(100)

A.Ruocco, M.P.Donzello,^y F.Evangelista, and G.Stefani Unita INFM and Dipartimento di Fisica, Universita Roma Tre Via della Vasca Navale 84, I-00146 Roma Italia

(D ated: M arch 22, 2024)

Re ection electron energy bos spectroscopy (EELS) in specular and o specular geom etry has been employed to study the early stage of the copper phthalocyanine (CuPc) grow th on Al(100) substrate. EEL spectroscopy has been a useful tool in order to study electronic structure of molecular in salso in the submonolayer regime. The electronic structure of the inst deposited layer of CuPc is strongly in uenced by charge transfer from the Al substrate to the low est unoccupied molecular orbital (LUMO). The strong molecule-substrate interaction gives rise to a coverage dependent frequency shift of the Al surface plasmon. Successive layers have essentially the electronic structure of the molecular solid. Momentum resolved EELS measurements reveal that, in the case of the thicker in investigated (22 A), the plane of the molecule is almost perpendicular to the surface of the substrate.

PACS num bers: 73.22.-f, 73.20 M f, 79.20 U v

I. IN TRODUCTION

M etal phthalocyanines, denoted M Pc (Pc = phtalocyanine C₃₂H₁₆N₈), have been synthesized using elements from any group of the periodic table. They are planar m olecules, closely related to biological m olecules such as porphyrins, constituted by a porphyrazin ring (porphyrin-like) bonded to four benzene rings. Main features of this class of molecules are a metal atom in the center (usually one of the rst transition series) and an extended -electron delocalization. MPc exhibit an high chem ical and therm alstability and exist in di erent form s; am ong the various polym orphs¹, the and ones are the best known and the most widely studied. In both crystalline form s the phthalocyanine units are positioned in colum nar stacks with the ring tilted with respect to the stacking axis (tilt angle), which cohere to form the molecular crystal. The two forms display identical interplanar distance (3.4 A) consistent with a Van der W aals bond, but they dier for the tilt angle: 26:5 in the form and 45**:**8 in the form. Furtherm ore their lattice param eters are di erent (23.9 A in the form and 19.6 A in form) as well metal-metal distance. The di erent the aggregation geometry results in changes of the electrical conductivity along the stacking direction. From an electronic point of view, MPc are sem iconductors whose gap width depends on the central atom (typically 1.5-1.8 eV) and slightly on the geom etrical arrangem ent (a variation of 60–70 m eV between the and form in the absorption spectra has been observed²). A fter p-doping by oxidizing agents and stabilization of a face to face stacking', MPcbecomeelectrical conductors thus enlarging their eld of applications. All these properties allow several technological applications in dierent elds such as non-linear optics, m olecular electronics and highly speci c gas-sensors fabrication (such as $NO_2^{4,5}$). Therefore the know ledge of M P c spatial and electronic structure, both as bulk crystals and as adsorbates on well-de ned

substrates, is much relevant. Over the past decade MPc overlayers have been studied interfaced with $m \text{ etals}^{6,7,8,9}$ sem iconductors^{8,10,11,12} and layered com pounds^{9,13,14}. Attempts have been made to grow them in an ordered manner (heteroepitaxy) on various substrates, som e of them of high technological interest^{15,16}. Substrate materials which have been shown to support the epitaxial grow th of phthalocyanine ultrathin Im s now include single crystal m etals, layered sem iconductors (SnS2, M oS2, HOPG), surface-passivated three dimensional sem iconductors (Si, G aA s, G aP), and insulators such as freshly cleaved single crystal halide salts¹⁷. In some cases an overgrow th evolution characterized by di erent m olecular orientations has been observed. In particular, the adsorption starts with planar arrangement at low coverages, when substrate-molecule interaction is believed to dom inate, to change into out-of-plane orientation at higher coverages where molecule-molecule interaction is expected to become relevant 1^{18} .

Recently, substrate surface reconstruction has been observed induced by molecular deposition and it has been speculated that it might be determined by strong molecule-substrate interaction. In particular, for CuPc/Ag(110) interface, the Ag surface reconstruction has been ascribed to the presence of facets¹⁹. More recently, for gold (110) surface has been detected a clear long range reordering of the substrate due to adsorption of CuPc²⁰. The capability of -conjugated molecules to induce displacements of surface atoms in conjunction with self-organised molecular grow th²¹ appears then to be a general characteristic that is relevant from a technological point of view and makes adsorption of this class of molecules, in perspective, an attractive option for nano manipulation of surfaces²².

A m ong m etals alum inum represents the archetypal for nearly-free-electron system s; therefore the A lsurface constitutes an interesting alternative to the m ore extensively investigated transition m etal substrates. In particular the absence of occupied d orbitals m ight highlight the role played by localization of the states in in uencing the electronic structure of an organic-inorganic interfaces. To the best of our know ledge A lsurface has never been studied as substrate for CuP c Im s deposition, apart from the case in which it was used to support thick Im s of CuP c. In this latter case, the aim was to analyze bulk interband m olecular transitions²³ and the in uence from the m etal-m olecule interface was not investigated.

The aim of this work is to study the growth mode and the molecular orientation of the overgrown Im as a function of its thickness, and to characterize the geom etric and electronic structure of monolayer and submonolayer CuP c Ims, deposited by therm alevaporation on an A 1(100) substrate. CuP c is a dye pigment therm ally very stable, thus allowing purication by sublimation technique and deposition by therm al evaporation or organic molecular beam epitaxy (OMBE)¹⁷. Electron energy loss spectroscopy (EELS) performed both in relection geometry and as a function of the ejection angle are the main spectroscopic tools applied in this work.

The literature reports on a limited number of EELS experiments on MPc lms in general and on CuPc lms in particular, most of them made in transmission geom – etry on thick lms, with high primary electron energy. Low energy electron energy loss spectra in rejection conditions have been measured on policrystalline lms of H_2Pc , CuPc, VOPc and PbPc^{24,25}, (prepared by sublimation under high vacuum 10⁷ 10⁸ mbar) on a Si substrate, with a primary electron energy of 100 eV. The spectra of all phthalocyanine com plexes exam ined have similar structures and the observed peaks in the ! excitations region are always in good agreem ent with the correspondent optical absorption data^{2,26}.

Although a limited number of works have made use of EEL spectroscopy to study MPc Ims, this technique is particularly attractive because it allows to examine an energy range corresponding to a region ranging from IR to soft X-ray in the electrom agnetic spectrum by using a laboratory based spectrom eter that can be easily conjugated to a growth chamber for in-situ investigation of the growth mechanism. Main target of this paper is to put in evidence the possibility to monitor the growth of thin lm s of C uP c, ranging from submonolayer to a few m onolayers, by the use of EEL spectroscopy and em phasize the potentiality of EELS technique in measuring the electronic properties of these Im s. Furtherm ore, the possibility to determ ine the orientation of the molecule with respect to the substrate has been shown. The latter result has been reached exploiting the relative orientation of transition dipole moment (i.e. the symmetry of the transition at 3.7 eV) and m om entum transferred in the collision. A sim ilar experiment, based on core tran-

sition, has already been perform ed in the case of sim pler

organic molecule adsorbed on metallic substrate²⁷.

II. EXPERIMENTAL

The experiments reported in this paper have been performed at the LASEC laboratory (D ip. di Fisica and Unita INFM, Universita R om a Tre) with an apparatus that allows to study thin Ims, grown in-situ, by a variety of electron spectroscopies, thus providing complementary informations on both electronic and geometric structure of the overlayer. In particular, the apparatus consists of two separate UHV chambers. The experimental cham – ber, equipped with an electron gun, a x-ray source and two emispherical analyzers, is devoted to spectroscopic investigations. A 5 degrees of freedom sample manipulator allows to control position in space and temperature of the sample. A comprehensive description of this apparatus is given elsewhere²⁸.

The preparation chamber features an electron bom – bardment evaporator $Tricon^{29}$ and a quartz crystalmicrobalance (QCM) used to control the growth rate of the

In s. The speci c nature of CuP c, i.e. the high condensability of the evaporated and its tendency to sublim ate forming needle-shaped crystals, m ade necessary to modify the evaporator source³⁰. The thickness of the molecular overlayer is not univocally determined by the rate of deposition onto the QCM as it depends upon the sticking coe cient and the deposition mode. Hence from the QCM measurements, a nominal thickness, corresponding to uniform coverage of the surface, is deduced. Furthermore, the preparation chamber features an ion gun for sputtering substrates and a magnetically coupled linear feedthrough for transferring sam ples.

The Alsubstrate is a single crystal (5 x 5 x 2.5 m m³) with (100) orientation and is supported by a molibdenum sample holder. Two di erent cleaning procedures have been adopted to remove the thick oxide layer always present on samples stored in air. The Alsurface was cleaned by electro polishing prior to introduction in the preparation chamber. The electropolishing was perform ed on an AB Electropolishing cell, Buchler Std, using a solution constituted of 345 m L of HC 10 $_4$ 60 % and 655 mL of $(CH_3CO)_2O$. The sample was then cleaned under vacuum by repeated cycles of sputtering with argon ions (4 keV, 67 $\,$ A) and annealing (450 $^{\circ}\text{C}$) 31 . The sam ple clean liness and order was checked before every deposition by m eans of AES and EELS.CommercialCuPc was obtained from A ldrich Chem ical (97 % dye content); it waspuri ed by sublim ation undervacuum (540-550°C, 10^{-2} 10^3 m bar) and then introduced in the molibdenum crucible of the electron bom bardment evaporator. The purity of the pow der was checked by elem ental analyses for C, H, N, perform ed by an EA 1110 CHNS-O CE instrum ent. Calculated for $C_{32}H_{16}CuN_8$: C, 66.72; H, 2.80; N, 19.45. Found: C, 66.58; H, 2.66; N, 19.34 %. (The uncertainty was 0.3 for C and 0.1 for H and N). The molecule was sublimated onto the substrate at room tem perature at a rate of approxim ately 0.5 A /m in. The lm, prepared in such a way, has been found stable until 400 °C and under electron bom bardment (im pinging current of few nA) does not su er evident radiation dam age; in sum mary it stays clean, under UHV condition, for at least 48 hours. The EEL spectra reported in the paper were collected at room temperature with one of the two em ispherical electron analyzers present in the experim ental cham ber. EELS m easurem ents were performed at xed incident kinetic energy and the overall energy resolution was 500 m eV throughout the whole range of incident electron energies (140 eV to 500 eV); the angular resolution was 0.5. Two di erent kinds of EEL spectra have been recorded in this work. In the

rst one the energy loss probability is measured in specular re ection conditions with a xed incident angle of 34 from surface norm al. In the second one the probability for a given energy loss was measured as a function of the transferred momentum by rotating the sam ple while keeping xed the included angle between the incoming and scattered beam s.

III. RESULTS AND DISCUSSION

In g.1 are reported the constant m om entum transfer EEL spectra m easured in specular re ection as a function of CuPc coverage, the nom inal thickness (from now on coverage) ranges from 1 A up to 22 A.All the spectra have been collected in specular re ection geom etry and with a prim ary energy of 140 eV in order to take advantage of the reduced m ean free path and then to be sensitive to the m olecular Im. The EEL spectrum of clean A lum inum is also reported for reference.

A. Interface plasm on

The clean Alspectrum is dom inated by two structures at 10.5 eV and 15 eV that correspond to the surface (SP) and bulk plasm on (BP), respectively. The intensity of the bulk plasm on drops with increasing coverage and alm ost disappears already for a coverage of 6 A . 0 n the contrary the surface plasm on shows a more articulate evolution. For the lowest coverages the centroid of this structure shifts towards lower loss energy; the shift increases as the thickness grows up to 3 A: in this situation it is not any more possible to resolve the surface plasm on from the molecular transitions appearing in the 5-8 eV region with similar intensity. The evolution of the SP with coverage is more evident in g. 2, where are reported the EEL spectra on the CuPc/Al(100) system, but with a prim ary energy of 500 eV, in order to highlight the interface excitations rather than the overlayer ones. It is then easier to follow the evolution of surface plasm on at very low coverages nding that it shifts toward lower loss energy when increasing the coverage and it reaches a steady value (8.5 eV) already at 4 A, wellbefore bulk-like conditions are ful led. It is therefore plausible to ascribe the SP peak to an interface plasm on such as those observed by Raether³² in the case of thin Im s deposited on m etal-

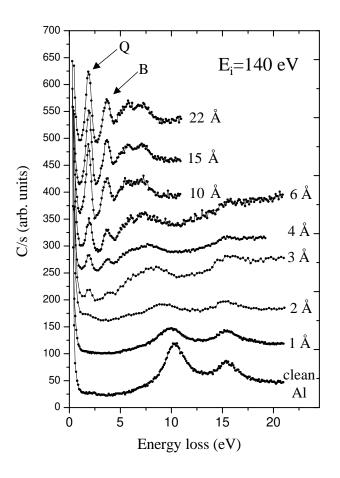


FIG.1: EEL spectra as a function of CuPc $\,$ In thickness perform ed in specular geometry with a primary energy of 140 eV. As a reference is also reported the EEL spectrum of the clean A lum inum .

lic substrate. M ore recently, a peak at 7 eV in the EEL spectrum of an Al surface exposed to O_2 has also been attributed to plasm a oscillations localized in the m etal substrate³³. To ascertain whether or not the observed SP transition corresponds to an interface plasm on, it can be considered that the energy of such a collective m ode is expected to disperse with the overlayer thickness unless the following condition is full lled³²:

where q_s is the momentum associated with the plasm a oscillation, i.e. the surface component of the momentum exchanged in the inelastic scattering (q), and d is the thickness of the lm. D ispersion of the plasm a frequency as a function of the thickness of the overlayer, was already observed for a thick Al lm (150A) covered with oxide layer³⁴. In our case q_s can be evaluated on the basis of the double collision model that is known to be valid^{28,35,36} for the energy loss processes in specular re ection geom etry. A coording to this model, the inelastic scattering is followed or preceded by an elastic one

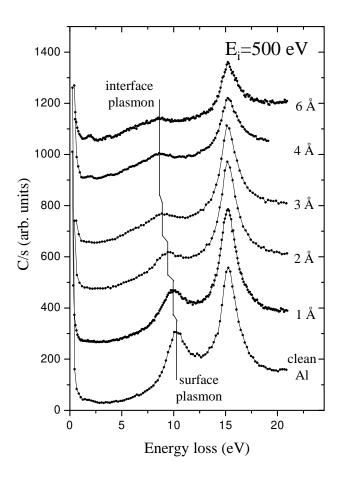


FIG. 2: EEL spectra as a function of CuPc lm thickness performed in specular geometry with a primary energy of 500 eV.As a reference is also reported the EEL spectrum of the clean A lum inum.

and the inelastic cross section can be assumed di erent from zero only for scattering angle falling within a cone of aperture $_{\circ} = E = 2E_{\circ}$ where E_{\circ} is the energy of primary beam and E is the energy lost in the collision. C onsequently the maximum q_s allowed is of the order of

 $_{\rm o}$ k_i' 12A ¹ where k_i is the incident m on entum. This explains the dispersion of the interface plasm on observed in g2, in particular the asymptotic value is reached for a coverage of 4 A that is the m inimum coverage to satisfy inequality 1 (g_sd = 4.8). Moreover, m aking the assum ption that the A l conduction electrons are well described by a free electron gas, the interface plasm on frequency is related to the dielectric constant of the molecular lm by the relation³²:

$$h!_{s} = \frac{p!_{p}}{1+"}$$
 (2)

From the measurements reported in g_2 we estimate for $!_s = 8.5$ eV and for $!_p = 15$ eV hence obtaining a value of 2.1 for the dielectric constant of the CuPc, a value that well agrees with those measured for other planar organicm olecules, with an extended delocalization of electrons, like benzene. All these nding support the hypothesis that the dispersing structure observed in g2 is to be ascribed to a surface plasm a wave propagating within the alum inum substrate whose frequency is modi ed by the dielectric response of the molecular adlayer. To the best of our know ledge this is the rst observation of an interface plasm on induced by organic molecule in alum inum.

B. M olecular transition

Electronic transitions due to the CuPc molecule becom e evident in the EEL spectrum starting from a coverage of 3 A; for this coverage two weak peaks centered at 1.9 and 3.7 eV (hereafter Q and B transitions respectively) appear together with a broad structure between 5 and 8 eV that is more intense than the Q and B transitions. Increasing the coverage, the Q and B transitions are always present: their intensities increase as a function of the coverage while their shape, energy position and relative intensity remain substantially unchanged. On the contrary the broad structure at 5-8 eV shows a modest evolution reaching its nalshape at 6A.For coverages of this value and higher the structure shows two prominent features located at 5.8 and 7.1 eV that are weaker than the B and Q transitions. It is interesting to note that starting from 10 A, the EEL spectrum does not show signi cant modi cations, thus suggesting that the molecular Im has reached a bulk-like con guration. This is con med by the observation that the energies at which electronic transitions appear do correspond to those reported in a previous work on thick CuPc $\ln s^4$. According to the diagram level of the CuPcm olecule as obtained from the four-orbitalm odel^{37,38,39}, the transitions at lower energies (E < 5 eV) appearing in g.1 are assigned mostly to ! electronic transitions of phthalocyanine molecules. In particular the peak at 1.9 eV, the Q band, is due to a mixture of a_{1u} ()! e_{q} () and b_{2q} ! b_{1q} transitions; although the two transitions are alm ost degenerate in energy, the form er has a dipole m om ent perpendicular to the molecular plane while the latter, mostly due to d orbitals from copper atom, has dipole m om ent in the plane of the m olecule. On the contrary the peak at 3.7 eV, the B band, is related to the single $a_{2u}()$! $e_g()$ transition thus having a well dened sym m etry with respect to the plane of the m olecule. W e also observe peaks at 5.8 eV, C band, and at 7.1 eV, X_1 band, both assigned to a ! transition. It is worth noting that there is a good agreem ent between the transition observed by means of EELS for the bulk-like coverages (10-22 A) and those obtained in the optical absorption spectra for thick Im of $CuPc^{26}$. Additionally, in absorption spectroscopy two other bands at 4.7 eV (N) and at 7.8 eV (X2) have been identi ed. We speculate that the form er transition (N) gives rise, in our spectra, to the low energy shoulder of the peak centered at 5.8 eV while the latter transition (X_2) is not detectable as

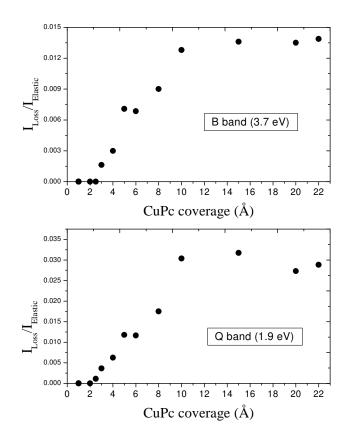


FIG. 3: Q and B band intensity, norm alized to the related elastic peak intensity as a function of CuPc coverage.

already reported in a previous EELS work²⁴.

g. 1, the Q and B transitions appear for cover-From ages of 3 A and higher. This threshold value correspond, in the hypothesis of a at lying adsorption geom etry, to saturating the surface with one monolayer. In this fram ework molecules from the st layer do not contribute to Q and B bands. In order to understand whether at low coverages these structures are simply confused in the background, or an alteration of the electronic structure occurs that forbids them, the Q and the B band intensities are plotted as a function of CuPc coverage (see g. 3). For coverages below 10 A we observe that the experimental data can be tted with a straight line whose intercept to zero corresponds to a coverage between 2 and 3 A. Hence, appearance of the optical absorption bands (Q and B) in the EEL spectrum has a clear threshold at a low non zero coverage. It in plies that the electronic structure of the rst adsorbed molecules is di erent from that of the bulk ones. We also notice that the threshold coverage of 2-3 A is consistent with the saturation value for one layer of at lying absorbed molecules. This behavior is con med by a similar investigation performed at 500 eV of incident energy³⁰. In other words we can make a clear distinction between molecules directly bonded to the Al substrate (coverage below 3 A) and m olecules not directly bonded to the substrate (coverage above 3 A). In the latter case the electronic structure, as revealed by EELS, is

identical to that of bulk CuPc while in the form er case m odi cation of the electronic structure is such to prevent transitions toward the LUMO orbital. Above 10 A we observe a saturation of the Q and B bands intensity. It is now important to understand why the optical transitions are inhibited form olecules directly bonded to the Al substrate. The simplest hypothesis to be made requires that, as a consequence of charge transfer, electrons from the Alsubstrate llup the molecular LUMO and the $3d_{x^2 v^2}$ orbitals. In order to 11 the LUMO (doubly degenerate) and the $3d_{x^2}$ $_{y^2}$ states, 5 electron perm olecule should migrate from the substrate. Roughly speaking, each CuPcm olecule covers about 32 A latom s, then each of this metallic atoms will contribute with about 0.16 electron to the charge transfer process. Considering the high density of nearly free electrons of the substrate, such a charge transfer is not unreasonable. Besides, a com parably large charge transfer it has already been observed in the case of C_{60} overlayer grown on A 1^{40} . Further support to the charge transfer mechanism comes from considerations on the molecular energy levels. For molecular solids grown on solid surfaces it was commonly assumed that organic-m etal interface energy diagram can be obtained by aligning the vacuum levels of the two materials. Recently it has been dem onstrated that this assumption is not always true for both $m \text{ etal}^{41}$ and sem iconductor substrates⁴². Vacuum level alignm ent applies only when the interaction between molecular Im and substrate is weak. As previously pointed out this is not our case. The charge transfer with consequent form ation of an ionic bond between CuPc and Alsubstrate in plies the form ation of a dipole barrier at the interface⁴². The presence of a surface dipole barrier is also supported by the consideration that the work function (WF) of alum inum is 4.3 eV while the electron a nity (EA) of the molecule (distance between LUM 0 and vacuum level) is only 3.1 eV. Then the 12 eV di erence between the two levels should prevent any charge transfer in the case of noninteracting interfaces. Our EELS analysis suggests that LUMO is led and then it is either aligned or it lies below the Ferm i level; we then conclude that the LUMO state of the molecules directly bonded to the metal shifts at least by 1.2 eV. Sim ilar results have been already observed for $C_{60}/Au(110)^{43}$; also in that case the authors claim for a charge transfer from the metal to the molecule even though, in that case, the di erence between the EA and W F is as large as 2.67 eV. In conclusion a sizeable charge transfer from substrate to molecule explains the observed threshold in coverage for appearance of optical bands in the EEL spectra.

${\tt C}$. ${\tt E}\,{\tt E}\,{\tt L}$ spectra as a function of the exchanged $$\tt m$ \mbox{ om entum}$$

The inelastic scattering in specular re ection geometry can be described by means of the double collision model (D C M) theoretically predicted³⁶ and experimen-

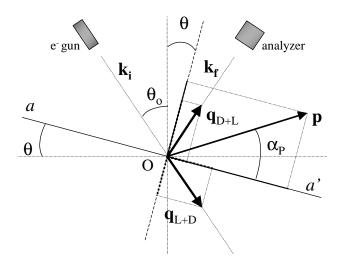


FIG. 4: Experimental geometry for the EEL spectrum as a function of the exchanged momentum. Electron gun and the analyzer are xed; $_{\rm p}$ is the angle between the dipole moment of the molecular transition and the surface of the sam – ple described by the plane aa'. The rotation of the surface is described by the angle and is the angle between the electron gun (the analyzer) and the norm alto the surface when specular conditions are satisfied.

tally veried^{28,35} for energy losses in the range 10 30 eV. In this model the measured electrons su er a double collision (one elastic and one inelastic) with the solid: in the elastic collision electrons are re ected from the surface, and in the inelastic one an energy loss occurs while scattering in forward direction. Concerning our experiment, the proposed model has two main implications: i) the smallness of the momentum exchanged in the inelastic collision, compared with the momentum of the incident electrons, allows to apply the dipole approximation, ii) two channels will incoherently contribute to the total cross section, that in which the elastic collision precedes (D + L) and that in which it follows (L + D) the inelastic collision. As previously pointed out the transitions at the lowest energies have a well de ned symmetry; in particular the B band, due to its unambiguous character, has dipole moment (p) perpendicu-1 lar to the plane of the molecule. The spatial orientation of the molecule can then be probed by changing, in the experim ent, the direction of dipole m om ent with respect to the momentum transferred in the inelastic collision. In this fram ework the cross section of EELS is proportional to p ģj thus the molecule orientation can be derived studying the EELS probability of the transition B as a function of the angle included between p and q. In g.4 is reported the kinem atics of the experim ent. A ccording to the DCM, two inelastic exchanged momenta are drawn directed along the directions of the incom ing beam (q_{L+D}) and of the collected beam (q_{D+L}) . P is

the angle form ed by vector p with respect to the surface

and it represents the orientation of the molecule. The

experiment was performed with the higher coverage (22

A), by scanning the angle , i.e. the angle between the norm alto the surface and the bisector of the included angle between incoming and outgoing electron beams (see

g.4). The directions of incident and di racted beam same xed in the laboratory reference frame, thus also (q_{L+L}) and (q_{L+D}) have a xed direction. By keeping xed the energy of incoming and outgoing electrons, the rotation of the sample results in a rotation of p and thus in a variation of the scalar product p q (q is not univocally determined, 2 values are present for each kinematics). It is more convenient to describe the process in the sample reference frame, where the scalar product between the exchanged momentum and dipole moment can be separately written for the two channels (L+D and D+L) as:

$$q \quad p_{+D} = [q_{2} p_{2} + q_{k} \quad p_{L+D}]$$

$$= qp [\cos() \quad) \sin_{p} + \sin() \quad) \cos_{p} \cos_{p} \cos_{p}]$$

$$q \quad p_{+L} = [q_{2} p_{2} + q_{k} \quad p_{D+L}]$$

$$= qp [\cos() + 1) \sin_{p} + \sin() + 1) \cos_{p} \cos_{p}] (3)$$

where the subscripts L+D and D+L take in account the presence of the two possible scattering channels previously discussed, represents the orientation of the molecule in the azimuthal plane and for $= 0_{n}p$ lies in the scattering plane. The di erential inelastic cross section will then be, as already shown elsewhere^{28,35}, the incoherent sum of the D + L and L + D cross sections. Hence, within First Born dipolar approximation the energy loss di erential cross section factors out in a kinematical term times the optical oscillator strength of the transition involved, times the sum of the two orientation term s appearing in 3. Taking into account that none of the studied interfaces has displayed a LEED pattern, an azim uthal random orientation of the adsorbed molecules can be safely assumed. This being the case, the dependence of the inelastic cross-section upon the polar angle reduces to the modulus square of the orientation factors averaged over the azim uthal angle beta, which is

$$j_{\rm H} \quad p^2 j' R \quad [cds() sin^2 p + \frac{1}{2} sin^2 () cos^2 p l_{\rm L+D} + (1 R) [cos(+) sin^2 p + \frac{1}{2} sin^2 (+) cos^2 p l_{\rm D+L}$$
(4)

R is the relative weight of the two channels and it depends essentially on the am plitude of the elastic com ponent of the cross section²⁸. In g.5 is reported the intensity of the transition B, norm alized to the related elastic peak intensity, as a function of the polar angle, expression 4 is a trial function with the scaling factor R used as a free parameter. The thing procedure has been repeated for several value of $_{\rm p}$ ranging from zero to 90. In the insert of g.5 is reported the 2 as a function of $_{\rm p}$ from

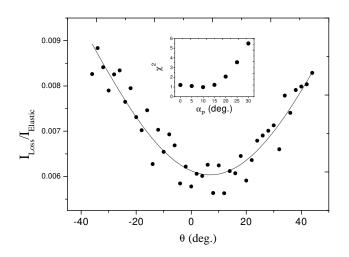


FIG.5: B band intensity (), normalized to the related elastic peak intensity, as a function of the polar angle. The continuous line is the best t obtained with the trial function (4) and $_{\rm p} = 15$. In the insert 2 values as a function of the $_{\rm p}$ parameter are reported.

which it is possible to conclude that the proposed model can be accepted for values of $_{\rm p}$ in the range 0-15 where the 2 is almost constant and equal to 1. From the structural point of view this correspond to have the plane of them olecule oriented almost perpendicular to the surface plane. The best R value is 0.54 that suggests an almost

equal probability for L+D and D+L scattering channels. This nding is in agreement with previous similar experiments on clean surfaces²⁸ that support the hypothesis of incoherent superposition of the two, equally relevant, scattering channels contributing to the EEL spectrum. Once more, momentum resolved EELS from adsorbed molecules has been shown to be a sensitive, accurate tool for determining orientation with respect to the substrate surface of thin molecular in s.

IV. CONCLUSIONS

In conclusion, the early stage of absorption of CuP c on the A1(100) surface has been studied by angle resolved EELS. The method has proven to be very sensitive and it allows to investigate coverages as low as 1 A. The rst m onolayer of m olecules su ers a massive charge transfer from the substrate inhibiting the optical B and Q absorption bands that are instead characteristic of bulk aggregation. This nding suggests that CuPc interacts with the Al substrate via a strong ionic bond. The molecule substrate interaction is also testi ed by the observed shift in frequency of the Alsurface plasm on. For the thick overgrown In the molecular plane is oriented predom in antly perpendicular to the substrate plane and, in contrast to the rst adsorbed layer, it does not show evidences for charge transfer from the substrate (B and Q band are restored).

E lectronic address: ruocco@ sunirom a3.it

- ^y present address: D ipartim ento diC him ica, U niversit a degli SudidiR om a La Sapienza, P.zzale A .M oro 5 00185 R om a, Italy
- ¹ C.C.Lezno and A.B.P.Lever, Phthalocyanines, Vol.1 (VCH Publ, New York, 1989).
- ² E.A.Lucia and F.D.Verderame, Journal of Chemical Physics 48, 2674 (1968).
- ³ E.Canadell and S.A lvarez, Inorganic Chem istry 23, 573 (1984).
- ⁴ S.Dogo, J.Germain, C.Maleysson, and A.Pauly, Thin Solid Film s 219, 251 (1992).
- ⁵ S.Dogo, J.Germain, C.Maleysson, and A.Pauly, Thin Solid Film s 219, 244 (1992).
- ⁶ S.Tokito, J.Sakata, and Y.Taga, Applied Physics Letters 64, 1353 (1994).
- $^7\,$ I. Sm olyaninov, Surface Science 364, 79 (1996).
- ⁸ G. Dufour, C. Poncey, F. Rochet, H. Roulet, M. Sacchi, M. De Santis, and M. De Crescenzi, Surface Science 319, 251 (1994).
- ⁹ K. W alzer and M. Hietschold, Surface Science 471, 1 (2001).
- ¹⁰ G.Dufour, C.Poncey, F.Rochet, H.Roulet, S.Iacobucci, M.Sacchi, F.Yubero, N.Motta, M.Piancastelli, A.Sgarlata, et al., Journal of Electron Spectroscopy and Related Phenomena 76, 219 (1995).
- ¹¹ J.Cox, S.Bayliss, and T. Jones, Surface Science 433, 152 (1999).

- ¹² J. Cox, S. Bayliss, and T. Jones, Surface Science 425, 326 (1999).
- ¹³ L. Ottaviano, S. D i N ardo, L. Lozzi, M. Passacantando, P. Picozzi, and S. Santucci, Surface Science 373, 318 (1997).
- ¹⁴ T. Shim ada, K. Ham aguchi, A. Kom a, and F. S. Ohuchi, Applied Physics Letters 72, 1869 (1998).
- ¹⁵ A.Kom a, Surface Science 267, 29 (1992).
- ¹⁶ H. Tada, K. Saiki, and A. Koma, Surface Science 268, 387 (1992).
- ¹⁷ C.C.Lezno and A.B.P.Lever, Phthalocyanines, Vol. 4 (VCH Publ., New York, 1996).
- ¹⁸ G. Poirier and E. Pylant, Science 272, 1145 (1996).
- ¹⁹ M.Bohringer, R.Berndt, and W.-D.Schneider, Physical Review B (Condensed Matter) 55, 1384 (1997).
- ²⁰ F.Evangelista, A.Ruocco, V.Corradini, C.Mariani, and M.G.Betti, Surface Science (submitted).
- ²¹ T.Yokoyam a, S.Yokoyam a, T.K am ikado, Y.Okuno, and S.M ashiko, N ature 413, 619 (2001).
- ²² C. Joachim, J. G im zew ski, and A. A viram, Nature 408, 541 (2000).
- ²³ M. Scrocco, C. E roolani, and A. Paoletti, Journal of Electron Spectroscopy and Related Phenomena 63, 155 (1993).
- ²⁴ H. Tada, K. Saiki, and A. Koma, Japanese Journal of Applied Physics, Part 2 (Letters) 28, L877 (1989).
- ²⁵ L. Bubnov and E. Frankevich, Sovietic Physics Solid State 16, 994 (1974).
- ²⁶ B.Schechtm an and W .Spicer, Journal of M olecular Spec-

troscopy 33, 28 (1970).

- ²⁷ T. Tyliszczak, F. Esposto, and A. Hitchcock, Phys. Rev. Lett. 62, 2551 (1989).
- ²⁸ A.Ruocco, M.M. ilani, S.N. annarone, and G. Stefani, Phys. Rev. B 59, 13359 (1999).
- ²⁹ R.Venucchiand S.Nannarone, Review of Scienti c Instruments 71, 3444 (2000).
- ³⁰ M. Donzello, PhD. thesis, Universit a La Sapienza, Rom a (2000).
- ³¹ R.Musket, W.McLean, C.Colmenares, D.Makowiecki, and W.Siekhaus, Applications of Surface Science 10, 143 (1982).
- ³² H. Raether, Excitation of plasmons and interband transitions by electrons (Springer-Verlag, Berlin, 1980).
- ³³ A.Ho man, T.Maniv, and M.Folman, Surface Science 193,513 (1988).
- ³⁴ T.K bos, Z.Phys. 208, 77 (1968).

- ³⁵ A.Ruocco, M.M. ilani, S.Nannarone, and G. Stefani, JournalDePhysique.IV : JP 9, Pr6 (1999).
- ³⁶ D.K.Saldin, Physics Review Letters 60, 1197 (1988).
- ³⁷ A.Scha er and M.G outerm an, Theoretica Chimica Acta 25, 62 (1972).
- ³⁸ A.Scha er, M.Gouterman, and E.Davidson, Theoretica Chimica Acta 30, 9 (1973).
- ³⁹ M. Gouterman, The Porphyrins, Vol. III, Part A (Academic Press, New York, 1978).
- $^{40}\,$ A .H ebard, P hysica B :C ondensed M atter 197, 544 (1994).
- ⁴¹ I. G. H ill and A. K ahn, Journal of Applied Physics 84, 5583 (1998).
- ⁴² I.G.H ill and A.K ahn, Journal of Applied Physics 86, 2116 (1999).
- ⁴³ A.J.M axwell, P.A.Bruhwiler, A.Nilsson, N.M artensson, and P.Rudolf, Physical Review B 49, 10717 (1994).